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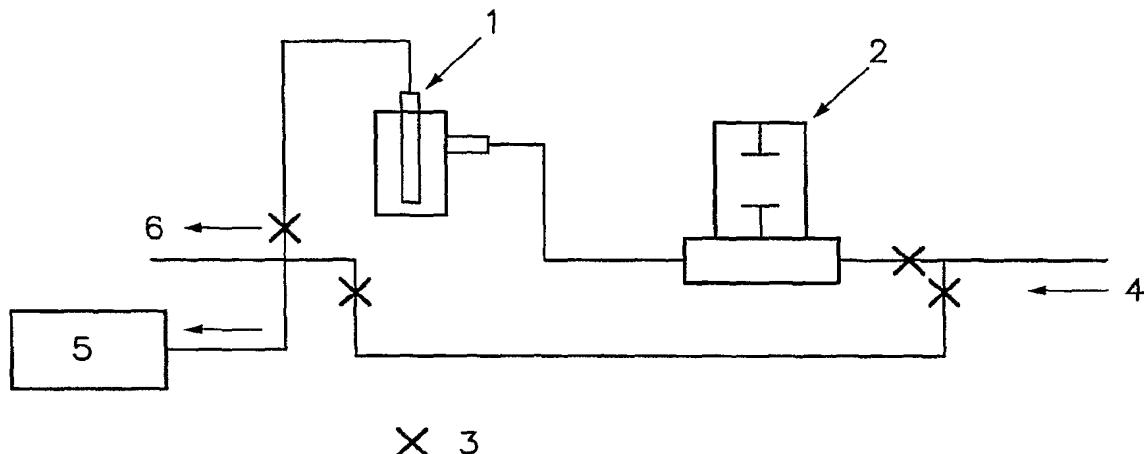
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(54) Title: METHOD OF FORMING A PLASMA AND USE FOR DECONTAMINATION BY DECOMPOSITION OF TOXIC SUBSTANCES



(57) Abstract: Method of forming a plasma intended for the chemical treatment of substances, in which at least two electrodes and a layer of dielectric material located between the two electrodes are placed in a chamber in order to form plasma glow discharges, in which a controlled flow comprising oxygen is introduced into the chamber, the controlled flow of gas during its introduction into the chamber containing none of the substances to be treated.

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